

# **PRODUCT DATA SHEET**

## 909 Hot/Wet Single Gas Mass Flow CEM

# Specifically configured for monitoring stack emissions on a mass rate basis

The AMETEK 909 is a single gas continuous emissions monitoring (CEM) system that measures stack effluent temperature and velocity, in addition to pollutant concentrations at stack conditions, enabling mass emission rates to be reported. With the addition of an optional zirconium oxide ( $ZrO_2$ ) sensor, the 909 is also capable of monitoring oxygen ( $O_2$ ).

The sample cell and all components in contact with the sample are heated above the dew points of all gases in the sample stream. This results in a more accurate calculation of gas concentrations, compared to other CEM systems that require water removal or sample dilution. No corrections for condensed and dissolved components are required. It also results in a simpler, more reliable analytical system as there is no need for sample drying. The 909 has built-in zero and span calibration and four zone temperature control (sample line, probe, sample conditioning unit, and oven).

### **Full function CEM**

As a full function CEM, the 909 performs all necessary sample gas and calibration gas flow management, as well as probe and sample line temperature control. Simply add a sample probe and sample line to be fully operational.

### Maximum reliability and durability

With a no-moving-parts design, the 909 is built for maximum reliability and durability. It is a complete system with a sample extraction and transport system designed to ensure sample integrity.

### High resolution ultraviolet (UV) technology

With a dual beam, dual wavelength configuration, a resolution of better than 0.02nm is provided by high-intensity line source lamps, enabling unparalleled linearity over a wide dynamic range, and leading to very accurate measurements. The dual beam configuration, combined with the reference measurement, ensures low noise performance with minimal baseline and span drift.



### 🕶 KEY BENEFITS

- High reliability and reduced maintenance (no moving parts)
- Sample and mass flow measurement in one device
- Hot/Wet analysis no water compensation or correction factors required
- Accuracy better than 2.5 parts per million (ppm) SO<sub>2</sub>
- No water (H<sub>2</sub>O) or carbon dioxide (CO<sub>2</sub>) interference
- Automated zero and span gas calibration
- Incorporates flow measurements for emission rate calculations

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### APPLICATIONS

- Sulfur recovery incinerators
- Sulfuric acid plants

### KEY MARKETS

Gas processing sulfur recovery

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### **PERFORMANCE SPECIFICATIONS**

| Methodology                              | Dual beam, high resolution, nondispersive UV  |  |   |
|--|---|--|---|
| Measurement and scale chart              | Species measurable           SO2           NO           NO2           H2S           NH3           Cl2   | <b>Minimum full scale</b><br>250 ppm<br>300ppm<br>125 ppm<br>125ppm<br>500 ppm | Maximum full scale 100% 100% 100% 100% 100% 100% 100% 100 |
| Optional O <sub>2</sub>                  | Integral ZrO <sub>2</sub>   |  |   |
| Accuracy                                 | Better than $\pm 1\%$ full scale of standard ranges   |  |   |
| Repeatability                            | Better than ±0.5% full scale of standard ranges   |  |   |
| Linearity                                | Better than ±1% of full scale   |  |   |
| Response time                            | Typically less than 30s to T90 (excludes sample system)   |  |   |
| Sample transport                         | Air aspiration  |  |   |
| Typical sample flow                      | 3 to 5 L/min (0.1 to 0.2 CFM)   |  |   |
| Temperature control                      | Independent control of three zones (oven, sample line, probe)   |  |   |
| Pressure and temperature<br>compensation | Standard  |  |   |
| Ambient temperature                      | 5 to 50°C (41 to 122°F)   |  |   |
| Instrument air                           | Minimum 413.6 KPa (60 psig), 120 L/min (4.24 CFM), instrument quality air   |  |   |
| Power                                    | 120 VAC ±10%, 47 to 63 Hz or 240 VAC ±10%, 47 to 63 Hz, 600 W for analyzer only   |  |   |
| Communications                           | Analog: (4) 4-20mA self powered<br>Digital: One RS232 port for service diagnostics. One RS422 with Modbus protocol<br>Relays: Three independent sets of SPDT relays alarm conditions  |  |   |
| Physical dimensions (W x H x D)          | 1117.6 x 1553.6 x 306 mm (44 x 61.17 x 12 in.)  |  |   |
| Weight                                   | Estimated minimum 160 kg (350 lbs.)   |  |   |
| Approvals and certifications             | NEC/CEC Class I, Division 2, Groups C & D<br>ATEX II 2 G Ex db eb pxb IIB T3 Gb<br>IECEx Ex db eb pxb IIB T3 Gb<br>GOST: ExpydIIBT3<br>Complies with all relevant European Directives |  |   |

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